

Continuous Processing of Thin-Film Batteries and Like Devices

Abstract of the Disclosure

5 A system for making a thin-film device includes a substrate-supply station that supplies a substrate having a major surface area. The substrate has a first layer on a first surface area of the substrate's major surface area. Also included is a device for depositing a second layer onto the first layer, wherein the device supplies energy to the second layer to aid in layer formation without substantially heating the
10 substrate.

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